

Displacement Damage Effect assessment :

a discussion about the NIEL scaling approach

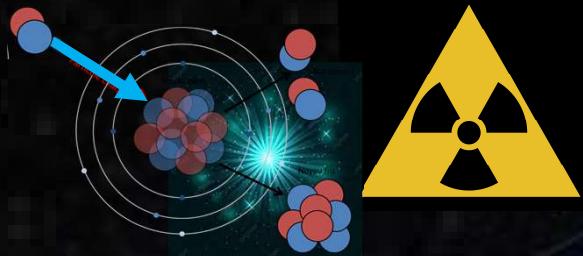
C.Inguibert

RADOPT 
29-30 Nov 2023
ISAE - Toulouse

OUTLINE

- Radiative space environment
- DOSE to quantify degradations
- Energy loss by unit path length : NIEL
- NIEL scaling approach
 - Relevance and observed deviations
- Conclusion & Perspectives

Natural and anthropic radiation environment



- Earth magnetic field traps charged particles (protons, electrons, ions)
- Radiation induced degradations

Material degradation

Optical, electrical, electronic & mechanical properties

Cumulative or sporadic degradations

Electronic devices sensitivity

Paintings yellowing



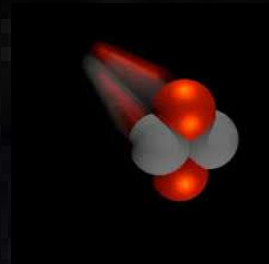
Solar array power loss



Noise in sensors

Single events

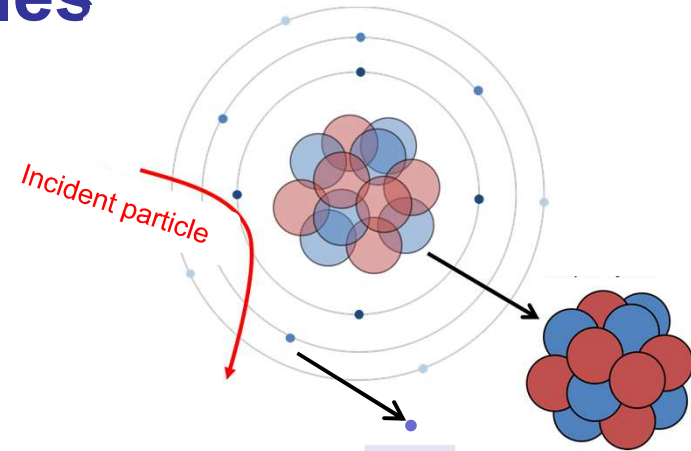
Charged Particles



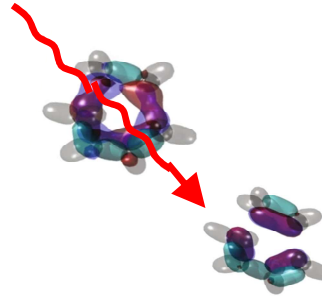
Ionizing radiations

Slowing down of incident particles

Slowing down = interactions with
electrons & nuclei



Broken atomic bounds



Electrons and
nuclei
are put into motion

Degradation (proportional to the number of interactions)

Each interaction = **ENERGY LOSS**

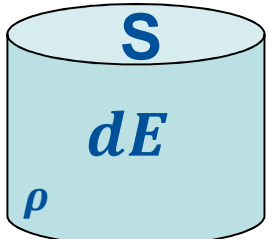
DOSE

DOSE & Energy loss by unit of length

Dose = deposited energy
by unit of mass
of the medium

$$Dose = \phi \frac{1}{\rho} \frac{dE}{dx}$$

ϕ Number of incident particle
 N Deposited energy
 dE
 $(\rho S dx)$ Density of the irradiated volume
 ρ Irradiated volume
 S Mass of the irradiated volume
 dx



$Degradation \propto Dose$

$$\frac{Degradation}{\Phi} \propto \frac{dE}{dx}$$

Displacement damage a specific radiation induced damage of optoelectronic devices

$$\left(\frac{dE}{dx}\right)_{Total} = \left(\frac{dE}{dx}\right)_{Electronic} + \left(\frac{dE}{dx}\right)_{Nuclear}$$

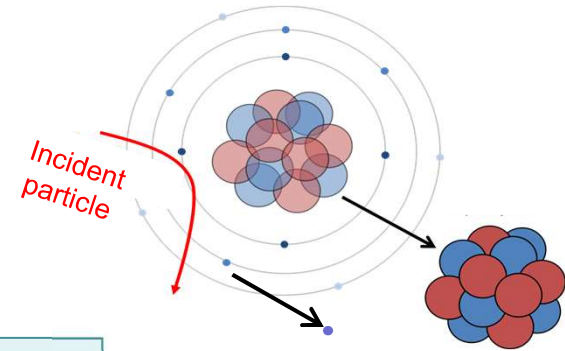
TID
Ionizing Dose = $\phi \times LET$

DDD
Displacement
Damage Dose = $\phi \times$

NIEL

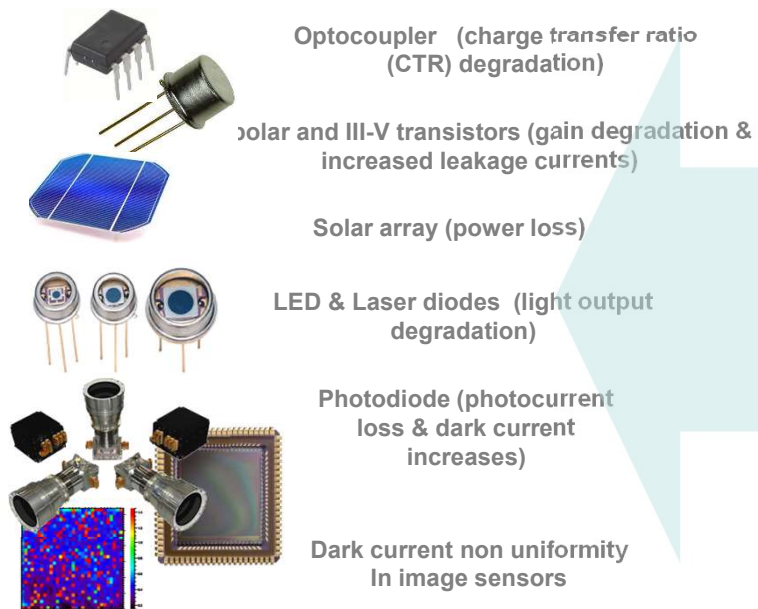
Non Ionizing
Energy Loss

NIEL scaling
approach

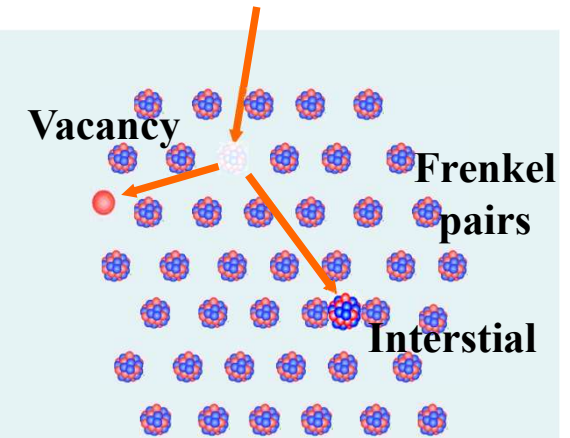


Degradations related to atomic displacements
by unit of fluence proportionnal to the NIEL

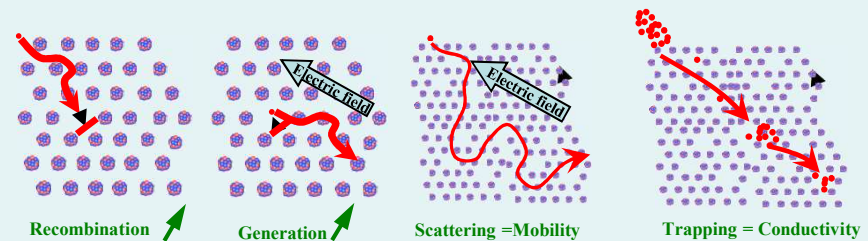
Displacement damage a specific radiation induced damage of optoelectronic devices



Electrical active defects that modify the Physical properties of semiconductors



Trapping → Conductivity reduction
Recombination → Mobility reduction
Carrier generation → Noise increase



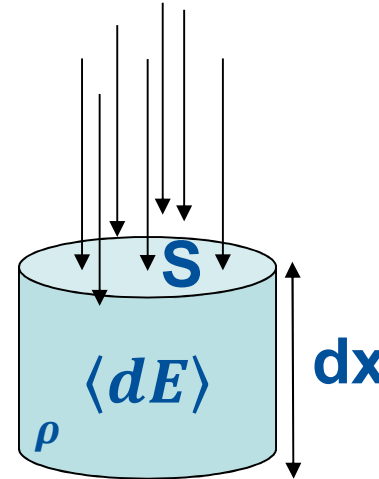
NIEL scaling approach

BUT the relevance of the degradation prediction lays on the accuracy NIEL



NIEL : an average parameter

$$DDD = N \frac{1}{\rho S} \frac{\langle dE \rangle}{dx}$$



Each incident particle deposit a different energy
DDD and NIEL make sense only for a large number of interactions in a way that the DDD is proportional to the total deposited energy

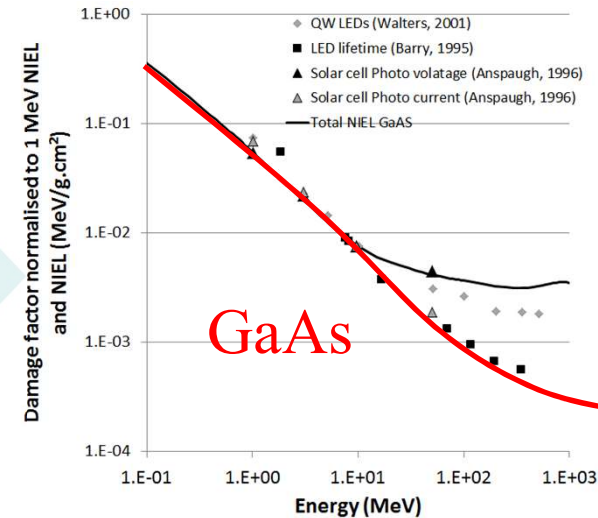
Degradation vs. applied fluence

$$\Phi = 10^{+09} \text{ protons/cm}^2$$

$$V = 100\mu\text{m} \times 100\mu\text{m} \times 10\mu\text{m}$$

E MeV	Number of interactions		
	Coulombian	nuclear elastic	nuclear inelastic
	mm	mm	mm
1	10000.0	2.2	0.6
10	1100.0	0.4	0.3
60	190.0	1.0	0.3
100	115.0	0.9	0.3
200	57.5	0.5	0.2
300	42.5	0.5	0.2

Number of interaction $\sim < 1$

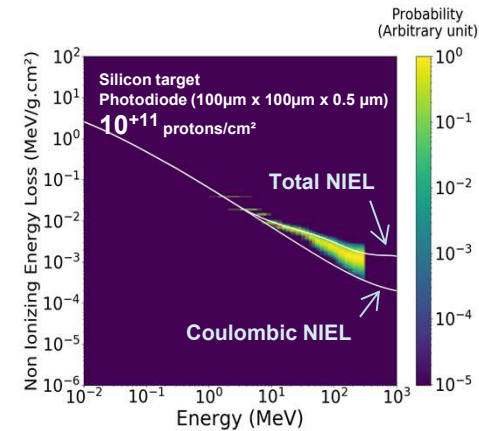
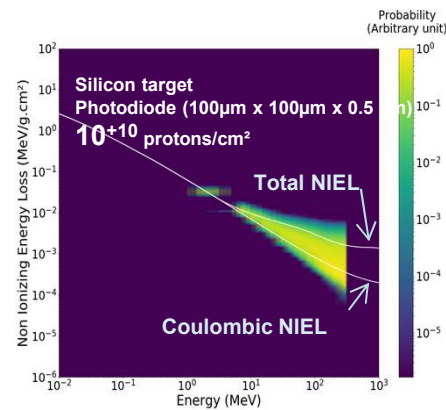
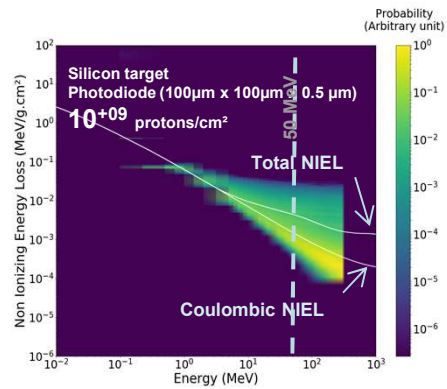


Si, GaAs, InGaAs

Damage factor
Coulombian dependence
For protons

NIEL is an **average** parameter which makes sense only if sufficient fluence has been applied
At **low fluence** level NIEL OVERESTIMATES the degradation

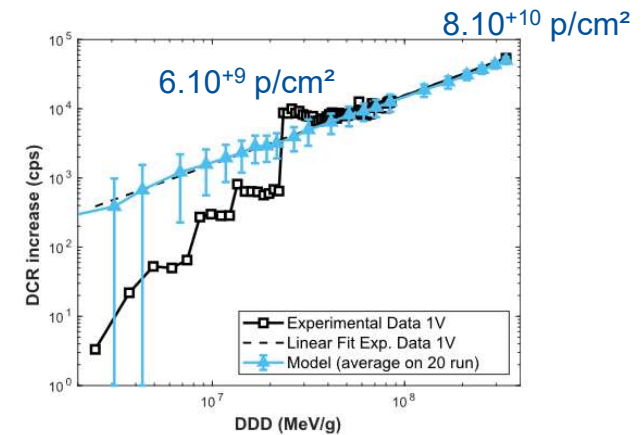
Degradation vs. applied fluence



C. Inguibert, et al. "Statistical spread on the displacement damage degradation of silicon photodiodes", Nuclear Instruments and Methods in Physics Research Section B: Beam Interactions with Materials and Atoms, vol. 490, pp. 7–17, Mar. 2021, doi: 10.1016/j.nimb.2021.01.002.

The most probable damage level of a device irradiated with a low fluence is lower than the NIEL explaining some deviations reported in the litterature

Experimental confirmation

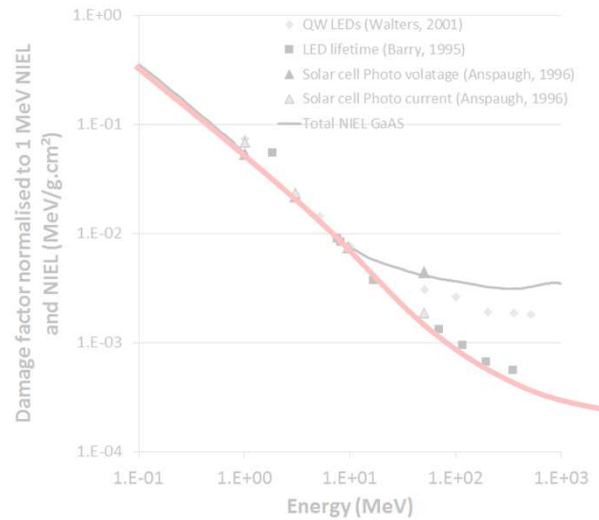


900 x 5µm x 5µm x ~1nm

Ali Jouni et al.
Proton-Induced Displacement Damages in 2-D and Stacked CMOS SPADs: Study of Dark Count Rate Degradation IEEE TRANSACTIONS ON NUCLEAR SCIENCE, VOL. 70, NO. 4, APRIL 2023

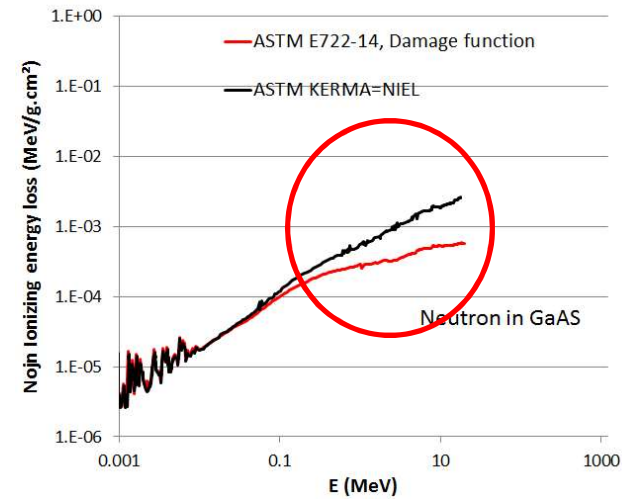
NIEL scaling law : observed deviations

Damage factor
Coulombian dependence
For protons



Si, GaAs, InGaAs

NIEL neutron
overestimation



GaAs



NIEL Dependence to the Threshold Damage energy E_d

$$\left(\frac{dE}{dx}\right)_{Total} = \left(\frac{dE}{dx}\right)_{Electronic} + \boxed{\left(\frac{dE}{dx}\right)_{Nuclear} \equiv NIEL}$$

E_d : limit under which an atom cannot be displaced

E_d is poorly known in most of cases

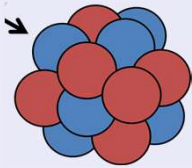
!!! NIEL of ELECTRONS Strongly depends on E_d



Reliability of ELECTRONS NIEL

500 keV

e-



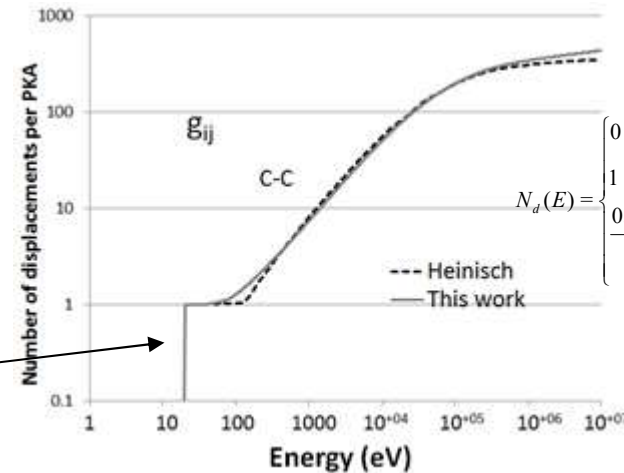
~ 50 eV

Maximum energy transfer

Lindhard partition function

$$NIEL(E) \propto \int_{E_d} \frac{d\sigma}{dE} \cdot n_d(E) \cdot dE$$

E_d

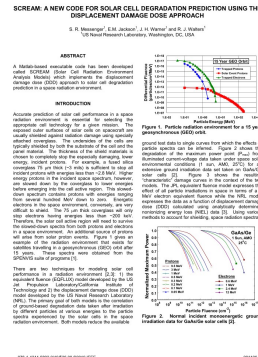


$$N_d(E) = \begin{cases} 0 & \text{if } E_{Damage} < E^d \\ 1 & \text{if } E^d \leq E_{Damage} < \frac{2 \cdot E^d}{0.8} \\ \frac{0.8 \cdot E_{Damage}}{2 \cdot E^d} & \text{if } \frac{2 \cdot E^d}{0.8} \leq E_{Damage} \end{cases}$$

A change in E_d strongly affects the NIEL of electrons

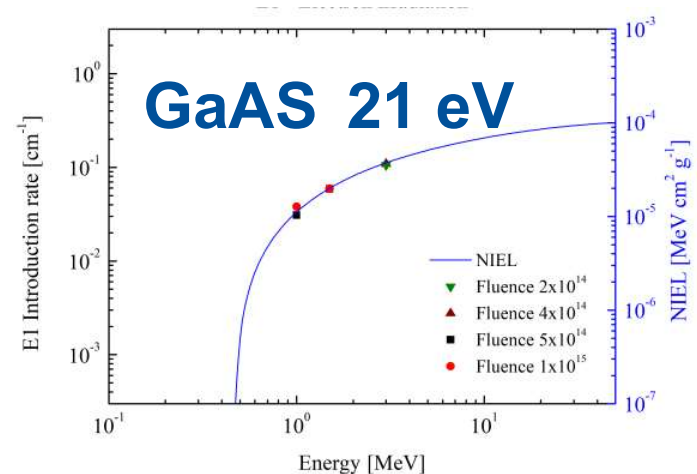
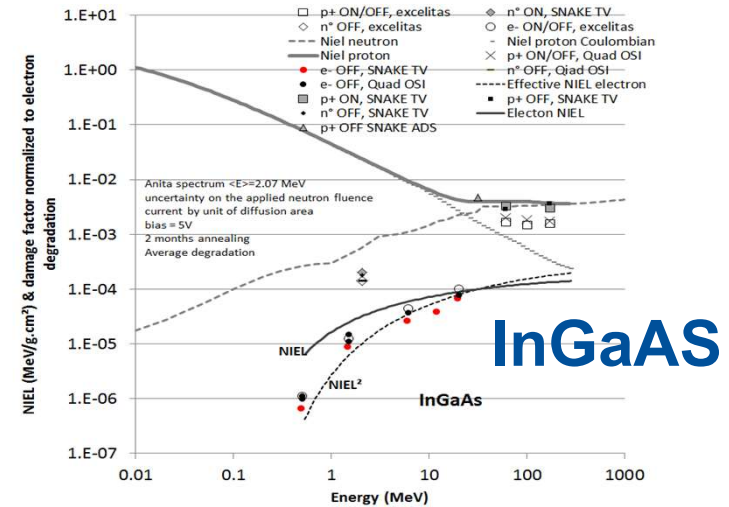
Observed NIEL deviation for electrons

NIEL scaling approach deviations observed in Si, InGaAs, GaAs...



Applying an empirical power factor for NRL solar cell degradation prediction method

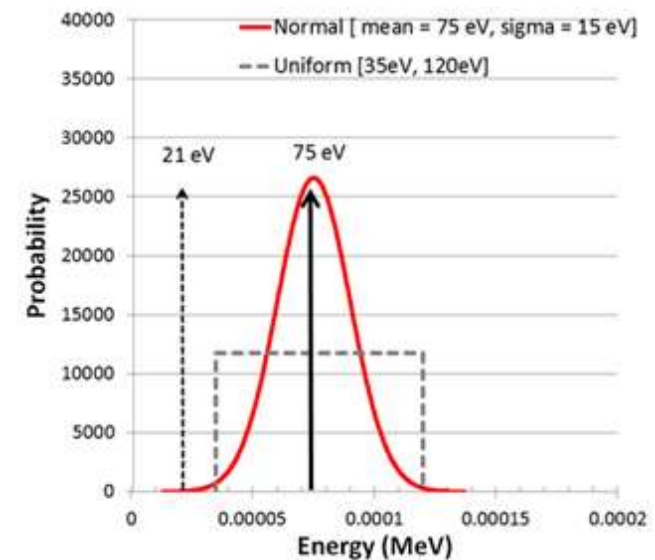
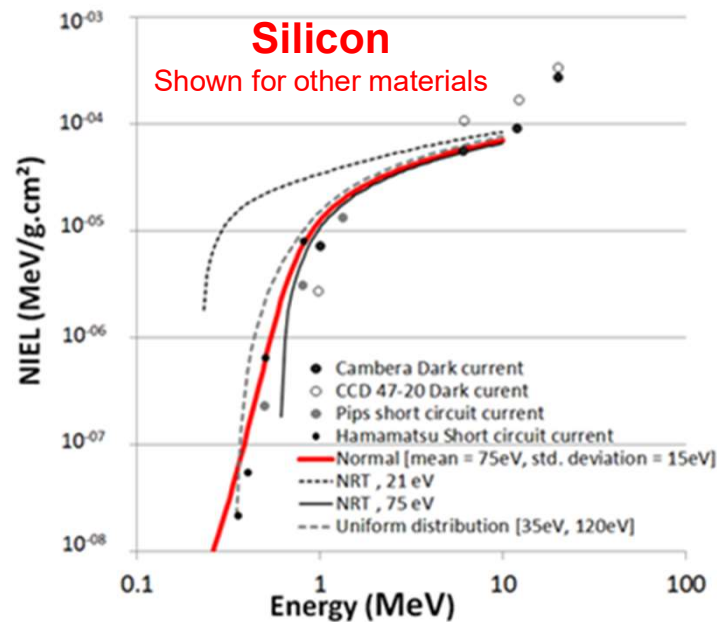
$$NIEL^\alpha \text{ avec } \alpha \in [1, 2,5]$$



R. Campesato, C. Baur, M. Casale, M. Gervasi, E. Gombia, E. Greco, A. Kingma, P.G. Rancoita, D. Rozza, M. Tacconi (2018), Effects of irradiation on Triple and Single Junction InGaP/GaAs/Ge solar cells, Proceedings of the 35th European PV Solar Energy Conference, Brussels, 24-28 September 2018,

Reliability of ELECTRONS NIEL

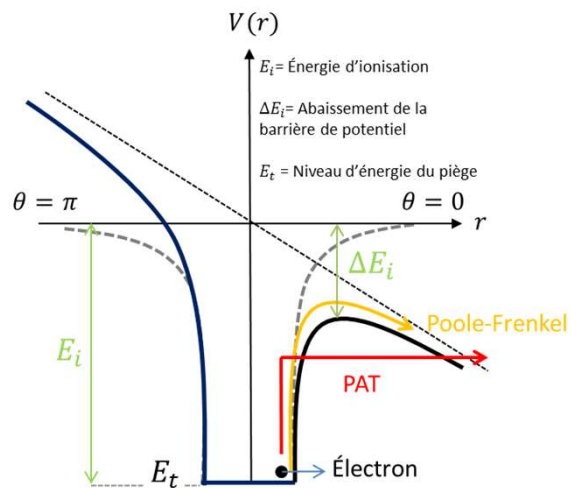
Including a distribution of threshold displacement damage energy provides NIEL in better agreement with experimental damage factors



C. Inguibert, "Including a distribution of threshold displacement damage energy on the calculation of the damage function and electron's Non Ionizing energy Loss," Journal of Nuclear Materials, vol. 559, p. 153398, Feb. 2022, doi: 10.1016/j.jnucmat.2021.153398.



Damage factors depends on the electric field



Enhanced generation rate due to electric field

- Poole Frenkel (lowered potential barrier)
- Phonon Assisted Tunneling

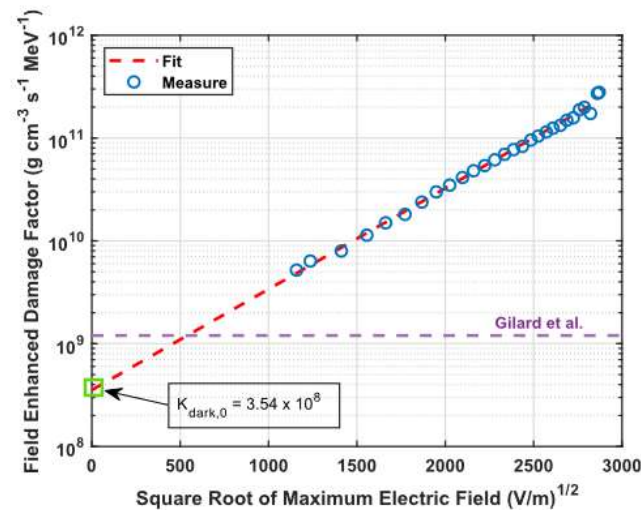
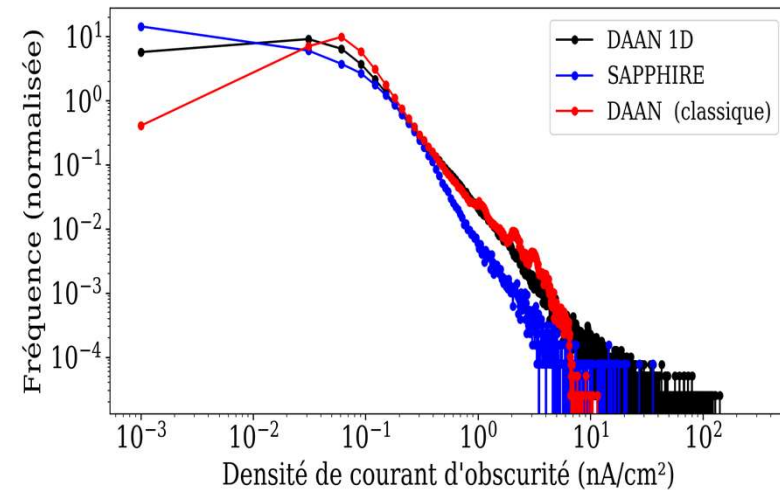
Importance of electric field

Better prediction of the tail of the Dark Current Non Uniformity

K. Lemière et al.
Influence of a 3D electric field enhancement model on the Monte Carlo calculation of the dark current in pixel arrays J. Appl. Phys. 128, 164502 (2020);

K Lemière PHD 2020

Mean enhancement
factor **x2** **Silicon**



Shown experimentally for InGaAs devices
Stronger magnitude than for Si devices

InGaAs Mean enhancement
factor **x5**

Marco Benfante & al.
Electric Field-Enhanced Generation Current in
Proton Irradiated InGaAs Photodiodes
IEEE TRANSACTIONS ON NUCLEAR SCIENCE, VOL. 70, NO. 4, APRIL 2023

Reliability of the NIEL scaling approach ?

NIEL SCALING WORKS QUITE WELL



Applied fluence

Threshold displacement damage energy(electrons)

Electric field

...

Degradation assumed proportional to the number of displacements ?

- Neglecting annealing effects,
- Neglecting nature of the defects,
- Neglecting electrical behaviours of the defects.

NIEL scaling puts aside the detailed functioning parameters of the devices

- Complexity of the devices functioning mode

Different traps at different locations,

Real carriers path through the device,

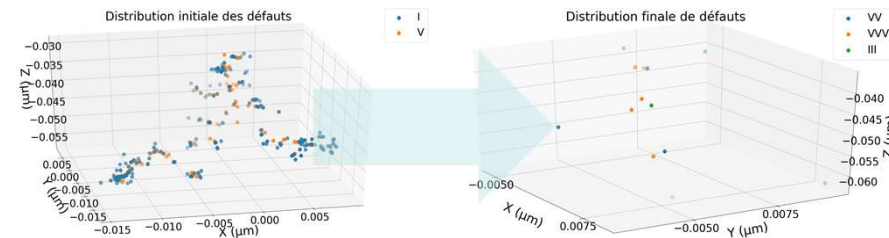
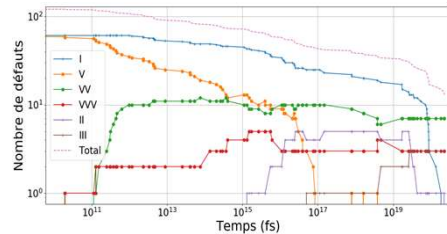
All electrical parameters do not show a linear response with NIEL

...

Conclusion & Perspectives

Need better knowledge of nature of defects with their physical characteristics

Atomic scale modeling (Ab initio, Molecular dynamic, Kinetic Monte Carlo)



T. Jarrin et al.
Simulation of Single Particle Displacement Damage in Si1-xGex Alloys—Interaction of Primary Particles With the Material and Generation of the Damage Structure
IEEE TRANSACTIONS ON NUCLEAR SCIENCE, VOL. 67, NO. 7, JULY 2020

